

## COMPOSITION INDUCED CHANGES IN OPTICAL RESPONSE OF $\text{Ti}_{(1-x)}\text{Si}_x\text{O}_2$ FROM FIRST PRINCIPLES CALCULATIONS

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### Abstract

Mixed  $\text{Ti}_x\text{Si}_y\text{O}_z$  materials offer interesting optical properties due to the high difference between refractive indices ( $\text{TiO}_2$ : ~2.5,  $\text{SiO}_2$ :~1.5) and band gaps ( $\text{TiO}_2$ : ~3.2 eV,  $\text{SiO}_2$ : ~8.5 eV). By changing composition a fine-tuning of the optical properties is possible. This opens new possibilities in design of optical devices.

In the present work, the variation of  $\text{Ti}_{(1-x)}\text{Si}_x\text{O}_2$  optical constants caused by changed Si concentration are examined by employing Density Functional Theory. Special Quasirandom Structures method is used to generate structural models of  $\text{Ti}_{(1-x)}\text{Si}_x\text{O}_2$  disordered solid solutions based on  $\text{TiO}_2$  and  $\text{SiO}_2$  phases. These initial supercells are structurally optimized (i.e. optimized with respect to the cell shape, size, and atomic positions) using the Vienna Ab initio Simulation Package. Ab initio Molecular Dynamics approach ("simulated annealing") is used to generate structural models of amorphous phase. Optical

constants of the resulting structures are calculated by the linearized augmented plane wave method as implemented in the Wien2k code together with the recently developed modified Becke-Johnson exchange-correlation potential allowing precise prediction of electronic structure and band gap. The calculated dielectric function is compared to the experimental

data obtained by fitting the optical measurements (ellipsometry, spectrophotometry) carried out on  $\text{TiO}_2$  and  $\text{Ti}_x\text{Si}_y\text{O}_z$  films prepared by plasma enhanced chemical vapor deposition and atomic layer deposition.

**Keywords:** Titanium dioxide, silicon dioxide, optical properties, mixed oxide, density functional theory